

(19)



Europäisches Patentamt

European Patent Office

Office européen des brevets



(11)

EP 0 697 278 A1

(12)

## EUROPEAN PATENT APPLICATION

(43) Date of publication:

21.02.1996 Bulletin 1996/08

(51) Int. Cl.<sup>6</sup>: B32B 15/08, B32B 31/20

(21) Application number: 95112727.3

(22) Date of filing: 12.08.1995

(84) Designated Contracting States:

DE FR GB IT NL

(30) Priority: 16.08.1994 US 291307

(71) Applicants:

- HOECHST CELANESE CORPORATION  
Somerville, N.J. 08876 (US)
- KURARAY CO., LTD.  
Kurashiki-City Okayama Prefecture 710 (JP)

(72) Inventors:

- Detlef, Frank  
D-55130 Mainz (DE)

- Penoyer, John A.  
Greenville, South Carolina 29616 (DE)
- Jester, Randy D.  
Greer, South Carolina 29654 (DE)
- Onodera, Minoru  
Kurashiki-city, Okayama (JP)
- Sato, Toshiaki  
Kurashiki-City, Okayama (JP)

(74) Representative: von Kreisler, Alek, Dipl.-Chem. et al  
D-50667 Köln (DE)

### (54) Liquid crystal polymer-metal laminate and a method of producing such a laminate

(57) A liquid crystalline polymer-metal laminate having one or more layers of a liquid crystal polymer film and one or more layers of a metallic foil, which when placed in a press and subjected to a pressure of between 5 to 100 bar, and a temperature greater than the melt point of the polymer film and less than the degradation temperature, and at a residence time of 0.5 to 1000 seconds produces a laminate having a minimum peel strength of 10 Newtons per centimeter and a dimensional stability of less than 0.2 %. Optionally, fiber reinforcement fabric can be employed in the laminate to provide increased mechanical strength or dimensional stability. Such a laminate is particularly useful for circuit boards.

EP 0 697 278 A1

**Description****1) Field of the Invention**

5 The present invention relates to a laminate of liquid-crystalline polymer and metal having characteristics suitable for the electronics industry. The present invention also relates to a process of producing the above-described laminate. In particular, the laminate can comprise a series of polymer-metal layers, as desired, for application as circuit boards, multi-layer printed boards, flexible interconnects, etc.

**10 2) Prior Art**

Liquid-crystalline polymers are well known as exemplified in the following U.S. Patents.

U.S. Patent 4,161,470 to Calundann discloses a polyester liquid-crystalline polymer formed primarily of reoccurring 6-oxy-2-naphthoyl (15 - 35 % by weight) and p-oxybenzoyl (65 - 85 % by weight) moieties. This polymer is commercially available under the tradename Vectran® from Hoechst Celanese Co.

Other liquid-crystalline polymers are known and described in "Polymer Liquid Crystals", by Ciferi, Krigbaum, and Meyer; published by Academic Press, 1981; and "High Modulus Polymers", by Zachariades, Porter, and Marcel; published by Dekker, Inc., 1988. Polymers of the type described therein are generally, but not limited thereto, fully aromatic polyesters, such as polyester carbonates, polyester amides, polyester imides, and similar polymers or block polymers.

20 U.S. Patent 4,737,398 to Ikenaga et al. describes a laminate of a liquid-crystalline polymer melt extruded onto a metallic film. Various metals such as copper, iron, aluminum, steel, magnesium, zinc, lead, etc. may be employed within the laminate. It is contemplated that the laminate film can be employed as a packaging material, sheet molding, electric wiring substrates, and body material.

25 U.S. Patent 4,966,807 to Harvey et al is primary directed to a film of biaxially oriented, liquid-crystalline polymer having a controllable coefficient of thermal expansion. Laminates of Vectran® and metal foils are described.

U.S. Patent 4,975,312 to Lusignea et al is directed to using biaxially oriented liquid-crystalline polymers for making printed wire boards. Such printed wire boards are produced from laminates of Vectran® and glass fabric/epoxy reinforcement.

30 German Patents 4,116,800 and 4,115,831 to Goldmann and Decker generally describe a method of laminating a film onto a fabric using a continuous high-pressure, high-temperature process, wherein the fabric includes a glass fiber mat.

35 Heretofor no one has developed a laminate of liquid-crystalline polymer film and a metal having properties such that the laminate can meet the strictest requirements of the electronics industries. The desired properties include good high peel strength, good dimensional stability and other optional properties such as solder bath stability.

**Summary of the Invention**

In the broad sense, the present invention relates to a laminate comprising of one or more layers of a liquid crystal polymer and one or more layers of a metal, having properties such that the laminate is useful in the electronics industry, including a peel strength of equal to or greater than 10 (N/cm) Newtons per centimeter according to the Institute for Interconnecting and Packaging Circuits (I.P.C.) 2.4.9. and a dimensional stability no higher than 0.2 % according to I.P.C. 2.2.4. Preferably, the peel strength is greater than 14 Newtons per centimeter and the dimensional stability is less than 0.05 %.

Also in the broad sense, the present invention relates to a method of producing the laminate comprising:

- 45 1. overlaying on one another an oriented liquid-polymer film and a metallic foil; and
2. bonding said foil to said film with a pressure between about 5 to 100 bar and at a temperature between the melt point of the polymer film and the degradation point of the polymer film.

50 The laminate of the present invention has certain advantages over known laminates of liquid-crystal polymers and metal foils, including those described in US-A-4,737,398. The chief advantages of the present invention are those of peel strength and good dimensional stability. Although the liquid-crystal polymer described in US-A-4,737,398 can be the same as employed in the present invention, the characteristics of good high peel strength and good dimensional stability are not inherent from the described laminate. Liquid-crystalline polymers of the present invention possess properties making them particularly suitable for use in the electronics industry. For example, these polymers have a low-moisture uptake such that there is no or very slight hygroscopic expansion and thus no change in electrical properties or dimensions. Metal laminates made from these polymers have good dimensional stability and peel strength over the temperature range of normal use for electronic applications. Additionally, no adhesive is necessary to bond the liquid-

crystalline polymer to the conductive material, although an adhesive can be used. Lastly, these polymers will not burn easily and thus accidental overheating will not ignite the polymer.

To make the laminate of the present invention, the liquid-crystalline polymers employed herein are described in U.S. Patent 4,737,398. Specifically, components of the polyester may comprise:

- 5 1. one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids;
2. one or more aromatic diols, alicyclic diols and aliphatic diols;
3. one or more aromatic hydroxy-carboxylic acids;
4. one or more aromatic thiocarboxylic acids;
- 10 5. one or more aromatic dithiols and aromatic dithiophenols; and/or
6. one or more aromatic hydroxy hydroxylamines and aromatic diamines.

Thus, the liquid-crystalline polymers of the present invention may comprise:

- 15 (I) a polyester containing components 1 and 2;
- (II) a polyester containing component 3 only;
- (III) a polyester containing components 1, 2 and 3;
- (IV) a polythiole ester containing component 4 only;
- (V) a polythiole ester containing components 1 and 5;
- 20 (VI) a polythiole ester containing components 1, 4 and 5;
- (VII) a polyester amide containing components 1, 3 and 6; or
- (VIII) a polyester amide containing components 1, 2, 3 and 6.

Further, though not included in the category of the above-mentioned combinations of components, aromatic poly-zomethyles may be cited as polymers capable of forming liquid-crystalline polymers. Typical examples of such polymers are: poly-(nitrilo-2-methyl-1,4-phenylene-nitriloethylidene-1,4-phenylene ethylidene); poly-(nitrilo-2-methyl-1,4-phenylene-nitrilomethylidene-1,4-phenylenemethylidene); and poly-(nitro-2-chloro-1,4-phenylene nitromethylidene-1,4-phenylene methylidene).

Although not included in the category of the above combinations of compounds, polyestercarbonates are included among liquid-crystalline polymers. These are composed essentially of 4-oxybenzoyl unit, dioxyphenyl unit, dioxygenyl unit, and terephthaloyl unit.

Enumerated below are chemical compounds which may constitute the components of above said items I) to VII).

Among the aromatic dicarboxylic acids are such aromatic dicarboxylic acids as terephthalic acid, 4,4'-diphenyl dicarboxylic acid, 4,4'-triphenyl dicarboxylic acid, 2,6-naphthalene dicarboxylic acid, diphenyl ether-4,4'-dicarboxylic acid, diphenoxymethane-4,4'-dicarboxylic acid, diphenoxymethylene-4,4'-dicarboxylic acid, isophthalic acid, diphenylether-3,3'-dicarboxylic acid, diphenoxymethane-3,3'-dicarboxylic acid, diphenoxymethylene-3,3'-dicarboxylic acid, and naphthalene-1,6-dicarboxylic acid; or the alkyl- or halogen-substituted of the above enumerated aromatic dicarboxylic acids, such as chloroterephthalic acid, dichloroterephthalic acid, bromoterephthalic acid, methyl terephthalic acid, dimethyl terephthalic acid, ethyl terephthalic acid, methoxy terephthalic acid, and ethoxy terephthalic acid.

Among the alicyclic dicarboxylic acids are such alicyclic dicarboxylic acids as trans-1,4-cyclohexane dicarboxylic acid, cis-1,4-cyclohexane dicarboxylic acid, and 1,3-cyclohexane dicarboxylic acid; or the alkyl-, alkoxy-, or halogen-substituted of the above enumerated alicyclic dicarboxylic acids, such as trans-1,4-(methyl)cyclohexane dicarboxylic acid, and trans-1,4-(1-chloro)cyclohexane dicarboxylic acid.

Among the aromatic diols are such aromatic diols as hydroquinone, resorcine, 4,4'-dihydroxy diphenyl, 4,4'-dihydroxy-triphenyl, 2,6-naphthalene diol, 4,4'-dihydroxy diphenyl ether, bis(4-hydroxyphenoxy) ethane, 3,3'-dihydroxy diphenyl, 3,3'-dihydroxy diphenyl ether, 1,6-naphthalene diol, 2,2-bis(4-hydroxyphenyl) propane, and 2,2-bis(4-hydroxyphenyl) methane; or the alkyl-, alkoxy-, or halogen-substituted of the above enumerated aromatic diols, such as chlorohydroquinone, methyl hydroquinone, 1-butylhydroquinone, phenyl hydroquinone, methoxy hydroquinone, phenoxy hydroquinone, 4-chloro resorcine, and 4-methyl resorcine.

Among the alicyclic diols are such alicyclic diols as trans-1,4-cyclohexane diol, cis-1,4-cyclohexanediol, trans-1,4-cyclohexane dimethanol, cis-1,4-cyclohexane dimethanol, trans-1,3-cyclohexane diol, cis-1,2-cyclohexane diol, and trans-1,3-cyclohexane dimethanol; or the alkyl-, alkoxy-, or halogen-substituted of the above enumerated alicyclic diols, such as trans-1,4-(1-methyl) cyclohexane diol, and trans-1,4-(1-chloro) cyclohexane diol.

Among the aliphatic diols are such straight-chain or branched aliphatic diols as ethylene glycol, 1,3-propane diol, 1,4-butane diol, and neopentyl glycol.

Among the aromatic hydroxy carboxylic acids are such aromatic dihydroxy carboxylic acids as 4-hydroxy benzoic acid, 3-hydroxy benzoic acid, 6-hydroxy-2-naphthoic acid, and 6-hydroxy-1-naphthoic acid; or the alkyl-, alkoxy-, or halogen-substituted or aromatic hydroxy carboxylic acids, such as 3-methyl-4-hydroxy benzoic acid, 3,5-dimethyl-4-hydroxy

benzoic acid, 2,6-dimethyl-4-hydroxy benzoic acid, 3-methoxy-4-hydroxy benzoic acid, 3,5-dimethoxy-4-hydroxy benzoic acid, 6-hydroxy-5-methyl-2-naphthoic acid, 6-hydroxy-5-methoxy-2-naphthoic acid, 3-chloro-4-hydroxy benzoic acid, 2-chloro-4-hydroxy benzoic acid, 2,3-dichloro-4-hydroxy benzoic acid, 3,5-dichloro-4-hydroxy benzoic acid, 2,5-dichloro-4-hydroxy benzoic acid, 3-bromo-4-hydroxy benzoic acid, 6-hydroxy-5-chloro-2-naphthoic acid, 6-hydroxy-7-chloro-2-naphthoic acid, and 6-hydroxy-5,7-dichloro-2-naphthoic acid.

Among the aromatic mercapto carboxylic acids are 4-mercaptopbenzoic acid, 3-mercaptopbenzoic acid, 6-mercaptop-2-naphthoic acid, and 7-mercaptop-2-naphthoic acid.

Among the aromatic diols are benzene-1,4-dithiol, benzene-1,3-dithiol, 2,5-naphthalene-dithiol, and 2,7-naphthalene-dithiol.

Among the mercaptophenols are 4-mercaptophenol, 3-mercaptophenol, 6-mercaptophenol, and 7-mercaptophenol.

Among the aromatic hydroxyamines and aromatic diamines are 4-aminophenol, N-methyl-4-aminophenol, 1,4-phenylene diamine, N-methyl-1,4-phenylene diamine, N,N'-dimethyl-1,4-phenylene diamine, 3-aminophenol, 3-methyl-4-aminophenol, 2-chloro-4-aminophenol, 4-amino-1-naphthol, 4-amino-4'-hydroxy diphenyl, 4-amino-4'-hydroxydiphenyl ether, 4-amino-4'-hydroxydiphenyl methane, 4-amino-4'-hydroxydiphenyl sulfide, 4,4'-diamino-phenyl sulfide (thiodianiline), 4,4'-diaminophenyl sulfone, 2,5-diaminotoluene, 4,4"-ethylene dianiline, 4,4'-diaminophenoxy ethane, 4,4'-diaminophenol methane (methylene diamine), and 4,4'-diaminodiphenyl ether (oxydianiline).

Among aforesaid polymer groups I) to VIII) composed of ingredients selected from among the above enumerated compounds may be some which are not capable of exhibiting anisotropic melt-phase forming characteristics, depending upon the types of the components, their proportions in the polymer, and their sequential distribution. It is noted that polymers used for the purpose of the invention are limited to those of the above enumerated which exhibit melt-phase anisotropy.

These polymers can easily be made as described in US-A-4,161,470 and US-A-4,737,398 (herein incorporated by reference) and some can be purchased under the tradename Vectra® from the Hoechst Celanese Co., Somerville, N.J., U.S.A.

The metals foils useful for the present invention include metallic alloys or metal-like compositions. In the class of metals is copper, silver, gold, iron, steel, including stainless steel, chromium steel, etc., zinc, brass, magnesium, nickel, molybdenum, copper/nickel, nickel/chromium, silicone-carbide compositions, and graphite, or mixtures of these for example.

Laminates can be formed by two different processes. The first process is described in Examples 1 to 8 of US-A-4,737,398. In this process, pellets of liquid-crystalline polymer are melt extruded through a "T" die extruder onto a metallic foil. Extruded liquid-crystalline polymer described in these examples has good mechanical strength in one direction only (see the Comparative Examples of US-A-4,737,398) and thus the metal foil is designed to provide a more balanced mechanical strength (see Examples 1 to 8 and Table 1 of US-A-4,373,398). This process does not produce acceptable peel strength and dimensional stability, particularly for very thin laminates. Additionally, it is very desirable to heat the metallic foil slightly below to slightly above ( $\pm 15^{\circ}\text{C}$ ) the melt point of the liquid crystalline polymer to achieve bonding. At these temperatures the metallic foil may oxidize (unless an inert gas is employed, which is very expensive), making the laminate unsuitable for electrical applications. Moreover, the extrusion process makes it very difficult to produce complex structures such as those described hereinafter.

The second process, which is claimed herein, melt extrudes a liquid-crystalline polymer onto a chill roll and stretch 40 orients the film in one or more directions or extrudes the film from an annular dye followed by orientation in one or more directions, as are known in forming polyester film. Thereafter, one or more pieces of the liquid-crystalline film can be overlaid on one or more pieces of a metallic foil, and subject to heat and pressure sufficient to bond the various layers into a laminate to yield structures, where

A = metal

B = polymer film

C = fabric,

such as A/B, A/B/A or B/A/B structures, A/B/A/B or B/A/B/A structures, A/B/C/B/A, A/B/B'/C/B/A, A/B/B', etc.

When a laminate is produced that has polymer film on one or both outer sides, it may be desirable to employ a release film between the polymer film and the platten of the press, so that no sticking of the polymer film to the platten occurs. Any release film, which does not interfere with or alter the characteristics of the polymer or laminate, would be suitable. The release film can be a polyimide, a fluoropolymer, or a release coated metal foil such as aluminum, for example.

Once the oriented liquid-crystalline polymer film (or films) is laid over the metal foil, the film is then bonded to the foil at a pressure between 5 to 100 bar at a temperature of more than the melt temperature of the polymer but less than its degradation temperature. At the temperature and pressure referenced above, the liquid-crystalline polymer undergoes a melt-phase enabling it to bond securely to the metallic foil, with a peel strength of equal to or greater than 10 N/cm and a dimensional stability no higher than 0.1 %.

This process can be a batch process, meaning that individual laminates can be formed one at a time with a stack press, for example, or a continuous process in which one or more rolls of oriented liquid-crystalline polymer film is laid

over one or more sheets of metallic foil, with or without one or more rolls of reinforcing fabric and bonded thereto by means of high pressure and temperature with a double belted press, for example. The residence time in the press when the liquid-crystalline polymer is above its melting point is 0.5 to 1000 sec. Prior art processes do not discuss this particular method of bonding a metallic foil in the form of a sheet to a liquid-crystalline polymer. The typical double belt press may have a heating and cooling zone of 1.4 meters wide by 2.0 meters long. Double belt presses are known per se, for example through Kurt Held GmbH, Trossingen-Schura, Federal Republic of Germany.

Of course, the amount of pressure and temperature applied to the liquid-crystalline polymer film and the metallic foil depends upon the type of polymer employed and upon the metallic foil employed and the physical and dimensional properties of each, along with the operational, physical and dimensional properties of the press. For example, the melt point of the polymer would be an important feature along with the thickness of the polymer, the thickness of the metallic foil as well as its ability to transfer heat, and of course how thick the multilayer structure is. Also, the heat transfer characteristics of the platten (of the press), its size and thickness, residence time of the laminate in the press, etc. are very important. For example, with a liquid-crystalline polymer formed primarily of recurring 6-oxy-2-naphthoyl and p-oxybenzoyl moieties (27 % by weight 6-oxy-2-naphthoyl, 73 % by weight p-oxybenzoyl), the temperature should be below approximately 350 °C and a particularly preferred temperature range is approximately 280 °C to 320 °C. While employing this particular liquid-crystalline polymer along with a copper metallic foil having an average thickness of 50 µm, the pressure to be applied to such an A/B laminate should be in the range of from 10 to 40 bar.

The liquid-crystalline polymers may include fillers and other additives well known in the art. Such fillers and additives may include, for example, organic or inorganic particles, plasticizers, light and weathering stabilizers, antistatic agents, ultraviolet absorbing agents, dyes, pigments, viscosity agents and lubricants.

In forming a laminate, it may be desirable to use a reinforcement fabric or material particularly when additional stiffness or dimensional stability is required. The reinforcement material can be, for example, a woven or non-woven fabric, such as carbon fabric, aramid fabric, glass fiber fabric, polyamide fabric, LCP fabric, quartz fabric, or mixtures of them, etc., as is known in the art.

The nominal metallic foil thickness can be from about 2 µm to about 500 µm. The liquid-crystalline film can be from about 10 µm to about 2500 µm thick. For printed circuit boards, the film is generally from about 25 µm to about 750 µm thick. Copper foil employed in printed circuit boards is generally between 5 µm to 100 µm thick. Typically, reinforcement fabric is in the range of 40 µm thick.

### 30 Experimental Conditions

The following tests were employed on the laminates in the subsequent examples. The brief description of these tests is more clearly set forth by reference to the Test Method Manual of the I.P.C., IPC-TM-650.

### 35 Peel Strength

Peel strength is determined in accordance with the Institute for Interconnection and Packaging Electronic Circuits (I.P.C.) test 2.4.9. The test determines the bond strength between copper foil and flexible dielectric support material.

A test specimen 9 inches long and ½ inches wide is cut from a laminate (a minimum of 4 specimens), 2 from the machine direction and 2 from the transverse direction. The testing machine is a power driven testing machine of the crosshead autographic type having a constant drive speed, such as a THWING ALBERT machine.

The specimens are conditioned for 24 hours at  $23 \pm 2$  °C and  $50 \pm 5$  % relative humidity. After attaching the specimen with the mechanical clamps, the foil is peeled from the flexible dielectric support material at a crosshead speed of 2 inches/minute for the entire sample. The peel strength is computed as the average force divided by the specimen width.

45

### Dimensional Stability

Dimensional stability is determined in accordance with I.P.C. 2.2.4 Method C, averaging at least 5 measurements. The test determines the thermal gradient dimensional changes of a plastic dielectric, which is metal clad. A test specimen is at least 10 ½ by 11 ½ inches with the machine direction being the longer dimension. Scribe 0.005 inch wide lines or punch holes on the specimen at corner points. Condition the specimen for 24 hours at  $23 \pm 2$  °C and  $50 \pm 5$  % relative humidity. Measure separation of lines between corresponding lines, or separation between holes. Chemically erode 100 % of the metal away at  $43 \pm 5$  °C using an etchant having no detrimental effect on the dielectric properties. Wash and dry. Place unconstrained, etched, conditioned and measured specimen in an oven at a temperature of  $150 \pm 2$  °C for 30 ± 2 minutes. Stabilize the specimen at  $23 \pm 20$  °C at  $50 \pm 5$  % relative humidity for a minimum of 24 hours. Remeasure separation of lines, or holes. The difference of the final measurements minus the initial measurements, divided by the initial measurements, times 100 yields the percent of change due to stress relaxation.

**Tensile Strength**

This test determines the tensile strength of the specimens in accordance with I.P.C. 2.4.19. Each specimen is 6 inches by  $\frac{1}{2}$  inch wide. A minimum of 10 specimens, 5 from the machine direction (MD) and five from the transverse direction (TD) are necessary. A THWING ALBERT tensile strength machine can be employed with the axis of the specimen coinciding with the center line of the gripping heads of the machine. Each specimen is conditioned for 24 hours at  $23 \pm 2$  °C at  $50 \pm 5$  % relative humidity. The gripping heads are initially set to 4 inches and the rate of grip separation is 2 inches per minute. Once the machine is started, it will record load versus extension. Tensile strength shall be the average of the specimens in the MD direction (and the same for the TD direction), each specimen tensile strength being calculated by dividing the load at break by the original cross sectional area.

**Solder Bath**

This test determines if the laminate can withstand specific thermal conditions, as described in I.P.C. 2.4.13. Four specimens, each 2 inches square were employed. For double clad laminate, the copper foil shall be etched from the non-test side of each specimen. Condition each specimen for 24 hours at  $23 \pm 2$  °C and  $50 \pm 5$  % relative humidity. Dip each specimen in molten flux for 5 to 10 seconds, then vertically drain for 60 seconds. Attach each specimen to the bottom of the cork float, metallic foil side down (away from cork surface) and hold float bottom surface just below the surface of the SN-60 molten solder maintained at  $260 \pm 5$  °C for 10 seconds, while agitating the specimens from side to side during immersion. Then remove and let excess solder drain. Examine each specimen for blistering, delamination or measling. These same procedures are also repeated except that the molten solder bath was maintained at 288 °C.

For the examples set forth subsequently, Vectran® A or C were employed. Vectran A comprises 73 mole % of p-oxybenzoyl (4-hydroxybenzoic acid) and 27 mole % of 6-oxy-2-naphthoyl (2,6-hydroxynaphthalic acid) available from the Hoechst Celanese Co., Somerville, N.J., U.S.A. Vectran C comprises 80 mole % of p-oxybenzoyl and 20 mole % of 6-oxy-2-naphthoyl also available from the Hoechst Celanese Co. All uniaxially oriented film is oriented only in the MD direction. The type of copper foil employed is an electro-deposited foil in which a drum is slightly dipped into a galvanic copper bath whereby copper is deposited on the surface of the drum, thus forming a foil; and then removed from the drum as is known in the art. The reinforcement fabric is type 106 woven glass fabric having a thickness of approximately 40  $\mu\text{m}$  (microns).

All laminate sizes for double belt press were 45 cm wide. All the examples employ Vectran A or C film. Because the melting temperature is about 282 °C and 312 °C, respectively, all laminates of the present invention using Vectran-C film satisfy the requirements for a good solder bath laminate, while Vectran-A film satisfies only the 260 °C solder bath conditions.

The following examples are presented to further illustrate the invention. However, these examples are not to be construed to limit the scope of the invention.

40

45

50

## Example 1 (Peel Strength)

Sample 1

5 Using a double belt press, both sides of a Vectran film were melt laminated to copper foil.

General Conditions:

10

Vectran type	A-resin - uniaxially oriented
Vectran thickness	125 µm
copper type	ED
copper thickness	35 µm
entrance zone temperature	220 °C
heating zone temperature	var.
cooling zone temperature	100 °C
belt speed	5 m/min
lamination pressure	25 bar

15

20

25

Results:

30

heating zone temperature [° C]	peel strength [N/cm]
260	11
280	14
300	16
320	20
340	25

35

40

45 This sample demonstrates that the desirable higher peel strengths are related to higher heating zone temperatures.

50

55

Sample 2

General Conditions:

5

10

15

20

25 Results:

Vectran type	A-resin - uniaxially oriented
Vectran thickness	125 µm
copper type	ED
copper thickness	35 µm
entrance zone temperature	220 °C
heating zone temperature	340 °C
cooling zone temperature	100 °C
belt speed	var.
lamination pressure	25 bar

30

35

Belt Speed [meter/minute]	peel strength [N/cm]
1	14
5	25
9	17

This sample demonstrates that if the residence time is too short, the peel strength can be adversely affected.

40 Example 2 (Anisotropic)

Sample 1

Using a double belt press, both sides of a Vectran film were melt laminated to copper foil. Then the copper laminate is etched away (in a manner described in I.P.C. 2.2.4) leaving only the Vectran film. Anisotropic ratio is the ratio of tensile modulus in the MD divided by the tensile modulus in the TD. Balanced films have an anisotropic ratio of 1.0.

50

55

General Conditions:

5

10

15

20

Vectran type	A-resin - uniaxially oriented
Vectran thickness	50 µm
copper type	ED
copper thickness	35 µm
entrance zone temperature	220 °C
heating zone temperature	var.
cooling zone temperature	100 °C
belt speed	3 m/min
lamination pressure	15 bar

Results:

25

30

35

heating zone temperature [° C]	anisotropic ratio
260	10
280	8
300	7
320	3
340	1

Generally, balanced films have the best dimensional stability. This example shows that starting with a uniaxially oriented film you can obtain a balanced film by controlling the heating zone temperature.

45

50

55

Sample 2

General Conditions:

5

10

15

20

Vectran type	C-resin - uniaxially oriented
Vectran thickness	50 µm
copper type	ED
copper thickness	35 µm
entrance zone temperature	220 °C
heating zone temperature	340 °C
cooling zone temperature	100 °C
belt speed	var.
lamination pressure	15 bar

25 Results:

30

35

belt speed [m/min]	anisotropic ratio
3	1
5	2
7	4

This sample shows that the residence time of the laminate in the press effects the anisotropic nature of the film.  
Shorter residence times (faster belt speed) result in poor anisotropic ratios.

40

45

50

55

**Example 3 (Dimensional Stability)**

Using a double belt press, both sides of a Vectran film were melt laminated to copper foil.

## 5 General Conditions:

10	Vectran type	C-resin - uniaxially oriented
	Vectran thickness	50 µm
15	copper type	ED
	copper thickness	18 µm
	entrance zone temperature	220 °C
	heating zone temperature	340 °C
20	cooling zone temperature	var.
	belt speed	1 m/min
	lamination pressure	27.5 bar

25

## Results:

30

cooling zone temperature [° C]	dimensional stability [%]
210	0.20
35 220	- 0.24
237	- 0.08
250	- 0.04
40 255	- 0.03

This example shows that the cooling zone temperature relates to the dimensional stability, with higher cooling zone temperatures yielding better dimensional stability.

45

**Example 4 (Homogeneity)**Sample 1

50 Using a double belt press, both sides of a Vectran film were melt laminated to copper foil. After removing the copper, a transparency pattern (MD-stripes) is observed.

55

General Conditions:

5

10

15

20

Results:

25

30

35

40

45

50

55

Vectran type	C-resin - biaxially oriented
Vectran thickness	30 µm
copper type	ED
copper thickness	18 µm
entrance zone temperature	220 °C
heating zone temperature	var.
cooling zone temperature	100 °C
belt speed	3 m/min
lamination pressure	35 bar

heating zone temperature [° C]	stripe pattern
300	no
320	weak
340	strong

A dependency of this stripe pattern on the heating zone temperature has been observed.

Sample 2

General Conditions:

5

10

15

20

Vectran type	C-resin - uniaxially oriented
Vectran thickness	50 µm
copper type	ED
copper thickness	18 µm
entrance zone temperature	220 °C
heating zone temperature	350 °C
cooling zone temperature	var.
belt speed	3 m/min
lamination pressure	35 bar

25 Results:

30

35

cooling zone temperature [° C]	stripe pattern
100	strong
200	strong
250	weak
270	no

40 A dependency of this strip pattern on the cooling zone temperatures has been observed.

**Example 5 (Reinforcement)**Sample 1

45

Using a double belt press, both sides of a Vectran film were melt laminated to copper foil. After removing the copper, the mechanical properties were measured.

50

55

General Conditions:

5

Vectran type	A-resin - uniaxially oriented
Vectran thickness	100 µm
copper type	ED
copper thickness	35 µm
reinforcement	glass fabric type 106 optional
entrance zone temperature	220 °C
heating zone temperature	320 °C
cooling zone temperature	100 °C
belt speed	5 m/min
lamination pressure	15 bar

10

15

20

Results:

25

30

reinforcement	tensile strength mega-pascals [MPa]
none	140
glass fabric	250

35

An improvement of mechanical properties by incorporating reinforcement fabric in the Vectran film was observed.

40

45

50

55

Sample 2

Using a double belt press, both sides of a Vectran film were melt laminated to copper foil.

## 5 General Conditions:

10	Vectran type	C-resin - uniaxially oriented
	Vectran thickness	100 µm
15	copper type	ED
	copper thickness	18 µm
	reinforcement	glass fabric type 106 optional
20	entrance zone temperature	220 °C
	heating zone temperature	350 °C
	cooling zone temperature	150 °C
	belt speed	3 m/min
	lamination pressure	30 bar

25

## Results:

30

reinforcement	dimensional stability
none	0.05
T 106 glass fabric	0.021

40 An improvement in dimensional stability by incorporating reinforcement fabric in the Vectran film was observed.

45

50

55

**Example 6 (Heat Sealing Layer)**

Using a double belt press, multiple layers of different types of Vectran have been melt laminated together.

## 5 General Conditions:

10	structure	ABA
	Vectran A-type	A-resin, uniaxially
15	Vectran A-thickness	50 µm
	Vectran B-type	C-resin, uniaxially
20	Vectran B-thickness	50 µm
	entrance zone temperature	220 °C
	heating zone temperature	var.
	cooling zone temperature	100 °C
	belt speed	3 m/min
	lamination pressure	30 bar

25

## Results:

30

heating zone temperature [° C]	delamination
260	easy
280	easy
300	easy
320	no
340	no

45 A dependency of delamination on the heating zone lamination temperature was observed. The melting point of Vectran A is about 282 °C and the melting point of Vectran C is about 312 °C. To obtain good bonded laminates it is important that all polymers achieve a melt phase state.

**Example 7**

50 A laminate is prepared using a stack press by overlaying: a 50 µm thick film of Vectran® A; a type 106 40 µm thick glass fiber mat; another layer of Vectran A (same thickness); and a 36 µm thick copper foil. The laminate was subjected to a pressure of 30 bar, at a temperature of 330 °C for 10 min. The temperature was increased from ambient and decreased from the 330 °C hold temperature at a rate of 10 °C per min. The original sample size was 45 x 45 cm. Good peel strength with cohesive failure inside the polymer film resulted.

55

**Example 8**

Films of Vectra A-resin were laminate to 35 µm ED copper foil utilizing a double belt press produced by Held GmbH. Lamination conditions were as follows:

## Sample 1

5

10

15

20

## 25 Sample 2

30

35

40

45

50

Vectra Type	A-resin uniaxially oriented
Vectra Thickness	50 µm
Copper Type	35 µm ED
Entrance Zone Temperature	220 °C
Heating Zone Temperature	305 °C
Cooling Zone Temperature	100 °C
Belt Speed	2.5 meters/min.
Lamination Pressure	27.5 Bar
Dimensional Stability (%) MD	0.09
Dimensional Stability (%) TD	0.02
Peel Strength	19.4 N/cm

Vectra Type	A-resin biaxially oriented
Vectra Thickness	60 µm
Copper Type	35 µm ED
Entrance Zone Temperature	220 °C
Heating Zone Temperature	275 progressing to 305 °C
Cooling Zone Temperature	100 °C
Belt Speed	6.5 meters/min.
Lamination Pressure	27.5 Bar
Dimensional Stability (%) MD	0.06
Dimensional Stability (%) TD	0.04
Peel Strength	14.7 N/cm
Dimensional Stability Test	I.P.C. 2.2.4 Method C (10X measurements)
Peel Strength after Solder Float	I.P.C. TM 650, Method C (260 °C Solder Temperature)

## Comparative Example 9

Films of Vectra A-resin were laminated to 35 µm ED copper foil by pressing the materials together in the nip formed between two rolls. The lamination was done at conditions of 280 °C, 30 kg/cm linear pressure, 3 meters/min. laminating speed. Examination of the dielectric and good adhesion indicated that a melt state was achieved in the lamination.

Measured properties were as follows:

Dielectric Material	MD Dimensional Stability %	TD Dimensional Stability %	Peel Strength pli
2 mil A-resin Uniaxially Oriented	0.33	- 0.74	6.4
5 mil A-resin Uniaxially Oriented	0.33	- 0.92	6.4
10 mil A-resin Uniaxially Oriented	0.36	- 0.87	6.3
1.2 mil A-resin Biaxially Oriented	0.24	- 0.17	6.1

\* 5X measurements per I.P.C. Test Specs.

Although adequate peel strength was achieved, acceptable dimensional stability was not achieved. The laminates produced are not acceptable for producing printed wiring boards.

Thus it is apparent that there has been provided, in accordance with the invention, both a laminate and a method that fully satisfies the aims and advantages set forth above. While the invention has been described in conjunction with specific embodiments thereof, it is evident that many alternatives, modifications, and variations will be apparent to those skilled in the art in light of the foregoing description. Accordingly, it is intended that the present invention will embrace all such alternatives, modifications and variations as fall within the spirit and scope of the invention.

### Claims

1. A process for producing a metallic laminate, comprising:

a. laying one or more oriented liquid-crystalline polymer films over a sheet of metallic foil; and  
 b. bonding said film and said foil in an isobaric press at a pressure of between 5 to 100 bar and at a temperature greater than the melt point of the liquid-crystalline polymer and less than the temperature at which the polymer starts to degrade, and at a residence time in said press when said film is above its melt point temperature of between 0.5 to 1000 sec.

2. The process of claim 1, wherein the liquid-crystalline polymer is selected from the class consisting of:

a. a polyester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, and one or more aromatic diols, alicyclic diols and aliphatic diols;  
 b. a polyester containing one or more aromatic hydroxy-carboxylic acids;  
 c. a polyester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, one or more aromatic diols, alicyclic diols and aliphatic diols; and one or more of aromatic hydroxy-carboxylic acids;  
 d. a polythioester containing one or more aromatic thiocarboxylic acids; or  
 e. a polythioester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, and one or more aromatic dithiols and aromatic thiophenols;  
 f. a polythioester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, and one or more aromatic thiocarboxylic acids, and one or more aromatic dithiols and aromatic thiophenols;  
 g. a polyesteramide containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, one or more aromatic hydroxy-carboxylic acids, and one or more aromatic hydroxylamines or aromatic diamines; and  
 h. a polyesteramide containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, one or more aromatic dithiols, alicyclic diols and aliphatic diols, one or more aromatic hydroxy-carboxylic acids and one or more aromatic hydroxylamines and aromatic diamines.

3. The process of claim 2, wherein said liquid-crystalline polymer is 15 to 35 % by weight 6-oxy-2-naphthoyl and 65 to 85 % by weight p-oxybenzoyl.

4. The process of claim 2, wherein said liquid-crystalline polymer includes one or more additives.

5. The process of claim 4, wherein said one or more additives is selected from the class of plasticizers, light-fast and weathering stabilizers, antioxidants, ultraviolet absorbing agents, antistatic agents, flame-retardant agents, dyes, pigments, lubricants and viscosity reducing agents.
- 5 6. The process of claim 1, wherein said metallic foil is selected from the class of copper, silver, gold, aluminum, iron, steel, zinc, tin, brass, magnesium, nickel, molybdenum, copper/nickel alloy, nickel/chromium alloy, silicone carbide alloy, graphite, or mixtures of these.
- 10 7. The process of claim 1, wherein said liquid-crystalline polymer film comprises one or more reinforced layers between one or more liquid-crystalline polymer layers.
- 15 8. The process of claim 1, wherein said liquid-crystalline polymer film comprises one or more woven or non-woven layers between one or more liquid-crystalline polymer layers.
9. The process of claim 1, wherein said liquid-crystalline polymer film comprises one or more layers of glass, carbon, aramid, etc. fiber between one or more liquid-crystalline polymer layers.
10. The process of claim 1, wherein said press is a batch operated stack press.
- 20 11. The process of claim 1, wherein said press is a continuous double belted press.
12. A liquid-crystalline polymer/metallic laminate comprising:
  - a) one or more layers of a liquid crystal polymer film; and
  - b) one or more layers of a metallic foil bonded to said film, wherein said laminate has a peel strength equal to or greater than 10 Newtons per linear centimeter and a dimensional stability less than 0.2 %.
13. The laminate of claim 12, wherein said film is selected from the class consisting of:
  - a. a polyester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, and one or more aromatic diols, alicyclic diols and aliphatic diols;
  - b. a polyester containing one or more aromatic hydroxy-carboxylic acids;
  - c. a polyester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, one or more aromatic diols, alicyclic diols and aliphatic diols; and one or more of aromatic hydroxy-carboxylic acids;
  - d. a polythioester containing one or more aromatic thiocarboxylic acids; or
  - e. a polythioester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, and one or more aromatic dithiols and aromatic thiophenols;
  - f. a polythioester containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, and one or more aromatic thiocarboxylic acids, and one or more aromatic dithiols and aromatic thiophenols;
  - 40 g. a polyesteramide containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, one or more aromatic hydroxy-carboxylic acids, and one or more aromatic hydroxylamines or aromatic diamines; and
  - 45 h. a polyesteramide containing one or more aromatic dicarboxylic acids and alicyclic dicarboxylic acids, one or more aromatic dithiols, alicyclic diols and aliphatic diols, one or more aromatic hydroxy-carboxylic acids and one or more aromatic hydroxylamines and aromatic diamines.
14. The laminate of claim 12, wherein said metallic foil is selected from the class of copper, silver, gold, aluminum, iron, steel, zinc, tin, brass, magnesium, nickel, molybdenum, copper/nickel alloy, nickel/chromium alloy, silicone carbide alloy, graphite, or mixtures of these.
- 50 15. The laminate of claim 12, wherein said laminate additionally comprises a reinforcing layer between two layers of said liquid crystal polymer film.
16. The laminate of claim 15, wherein said reinforcing layer comprises a woven or non-woven fabric.
- 55 17. The laminate of claim 16, wherein said fabric is selected from the class of glass, carbon, aramid, polyimide, quartz, boron, vectran, ceramic or mixtures thereof.



European Patent  
Office

## EUROPEAN SEARCH REPORT

Application Number  
EP 95 11 2727

DOCUMENTS CONSIDERED TO BE RELEVANT			CLASSIFICATION OF THE APPLICATION (Int.Cl.6)
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	
X	WO-A-89 12547 (FOSTER MILLER INC) 28 December 1989 * page 13, line 23 - page 14, line 18 * * page 15, line 33 - line 35 * * page 17, line 16 - line 25 * * page 19, line 30 - page 21, line 14 *	1,2,6, 12-14	B32B15/08 B32B31/20
Y		3-5, 7-11, 15-17	
D	& US-A-4 966 807 (...) ---		
X	US-A-4 863 767 (GARG ET AL.) 5 September 1989 * example 3 *	1-3,6,10	
Y	EP-A-0 502 190 (DAICEL CHEM) 9 September 1992 * page 2, line 55 - page 3, line 15; claims; table * * page 4, line 38 - line 58 * * page 9, line 24 - line 58 *	4,5,10, 11	
A		1-3,6, 10-14	TECHNICAL FIELDS SEARCHED (Int.Cl.6)
Y	EP-A-0 184 368 (POLYPLASTICS CO) 11 June 1986 * table 2, examples 13-17 * * page 34, line 8 - line 12 * * page 35, resin C *	3	B32B
A		1,2,4-6	
Y	DATABASE WPI Section Ch, Week 8715 Derwent Publications Ltd., London, GB; Class A94, AN 87-106379 & JP-A-62 055 131 ( MITSUI TOATSU CHEM INC ) , 10 March 1987 * abstract *	7-9, 15-17	
		-/-	
<p>The present search report has been drawn up for all claims</p>			
Place of search	Date of completion of the search	Examiner	
THE HAGUE	13 October 1995	Pamies Olle, S	
CATEGORY OF CITED DOCUMENTS		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ..... & : member of the same patent family, corresponding document	
X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document			



European Patent  
Office

## EUROPEAN SEARCH REPORT

Application Number

EP 95 11 2727

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cl.6)
A	<p>WO-A-89 01407 (OLIN CORP) 23 February 1989</p> <p>* page 6, line 2 - page 7, line 10; claims; example 4 *</p> <p>* page 9, line 1 - line 12 *</p> <p>* page 10, line 1 - line 7 *</p> <p>-----</p>	1-6, 10-14	
			TECHNICAL FIELDS SEARCHED (Int.Cl.6)
<p>The present search report has been drawn up for all claims</p>			
Place of search	Date of completion of the search	Examiner	
THE HAGUE	13 October 1995	Pamies Ollie, S	
CATEGORY OF CITED DOCUMENTS			
<p>X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document</p>		<p>T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ..... &amp; : member of the same patent family, corresponding document</p>	

